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(71)Applicant: KYOWA YAKUHIN KOGYO KK

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(72)Inventor: HIRATA KENJI

KATO YUTAKA NISHIMURA AKI YAMASHITA JUNYA

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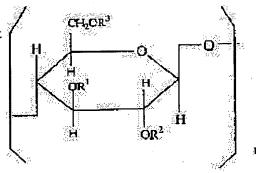
(54) PHARMACEUTICAL PREPARATION FOR RESTORING BEDSORE AND DAMAGED SKIN (57) Abstract:

PROBLEM TO BE SOLVED: To obtain a pharmaceutical preparation for restoring bedsore and damaged skin in the form of an ointment containing active ingredients such as refined sugar and povidone—iodine having

stability for a long period without using a shape retaining agent or a buffer agent, having extensibility and excellent

in feeling of use.

SOLUTION: This pharmaceutical preparation for restoring bedsore and damaged skin contains 0.5-5.0 wt.% of at least one kind selective from the group consisting of a lithium salt, a sodium salt, a magnesium salt, a potassium salt, a calcium salt, a zinc salt and an ammonium salt of alginic acid or the salts of a derivative of polysaccharides represented by the following formula [R1, R2 and R3 may each be same or different and at least one kind thereof is carboxymethyl group; the remaining groups are each hydrogen atom, methyl group or ethyl group; the bond between mutual pyranose rings may be an α -1,4 bond or a β -1,4 bond; (n) is a natural



number] as a stabilizer in the pharmaceutical preparation for restoring the bedsore and damaged skin containing 50-90 wt.% of a sugar, 0.5-10 wt.% of povidone-iodine and 1-20 wt.% of water.

LEGAL STATUS

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